

Application No.: 10/682,039

Docket No.: 0465-1063P



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Eung Chul PARK et al.

Application No.: 10/682,039

Confirmation No.: 7995

Filed: October 10, 2003

Art Unit: 1755

For: POLYCRYSTALLINE MgO DEPOSITION
MATERIAL HAVING ADJUSTED Si
CONCENTRATION

Examiner: K. E. Group

AMENDMENT

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Examiner's Office Action dated January 11, 2005, the Response to which has been extended until June 11, 2005, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

This paper includes Amendments to the Claims and Remarks.